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INFORMATION DISCLOSURE STATEMENT BY APPLICANT MAR 0'5 2002				APPLICANT Peter V. Schwartz	· · · · · · · · · · · · · · · · · · ·			
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6-25-04 *EXAMINER: INITIAL IF CITATION CONSIDERED, WHETHER OR NOT CITATION IS IN CONFORMANCE WITH MPEP 609; DRAW LINE THROUGH CITATION IF NOT IN CONFORMANCE AND NOT CONSIDERED, INCLUDE COPY OF THIS FORM WITH NEXT COMMUNICATION TO APPLICANT.

DATE CONSIDERED

EXAMINER